

FEB 25 2008

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Heng Liu
Assignee: BridgeLux, Inc.
Title: Chemical Vapor Deposition Reactor
Application No.: 10/727,746 Filing Date: December 3, 2003
Examiner: Ram N. Kackar Group Art Unit: 1763
Docket No.: M-15626-1D US Confirmation No.: 8880

Irvine, California
February 25, 2008

Via Facsimile to (571) 273-8300

Mail Stop AMENDMENT
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

PETITION FOR EXTENSION OF TIME

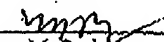
Dear Sir:

Applicants respectfully petition for a TWO-month extension of time within which to respond to the Office Action mailed September 24, 2007, such extension allowing Applicants until Monday, February 25, 2008 to respond.

Please charge the amount of \$230.00 (for a small entity) as set forth in the accompanying Transmittal Letter.

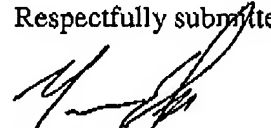
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I hereby certify that this paper is being facsimile transmitted to the U.S. Patent and Trademark Office on the date shown below.


Monique M. Butler

February 25, 2008
Date of Signature

Respectfully submitted,


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